



IM/ AF:

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 6339**
Kazufumi SATO et al. : Docket No. 2003_1687
Serial No. 10/716,632 : Group Art Unit 1752
Filed November 20, 2003 : Examiner Yvette C. Thornton
POSITIVE-WORKING PHOTORESIST **Mail Stop: AF**
COMBINATION

RESPONSE TO FINAL REJECTION

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

In response to the Final Rejection dated February 9, 2005, please amend the present application as follows: